



China best price Electronic Grade Cylinder Sih4 Gas Silane Gas

Our Product Introduction

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Basic Information

- Place of Origin: China
- Brand Name: CMC
- Certification: COA
- Model Number: sih4
- Minimum Order Quantity: 1kg
- Price: US \$ 45/kg
- Packaging Details: Cylinder/Tank
- Delivery Time: 15 days
- Payment Terms: L/C, T/T
- Supply Ability: 50000kg/month



Product Specification

- Product Name: Silane
- Purity: 99.9999%
- Transport: By Sea
- Appearance: Colorless
- Model No.: Silane Gas
- Transport Package: Y-Cylinder, T-Drum, T-Cylinder, T-Drum, Tt, Tanker
- Specification: 20L, 40L, 280L And Customizable
- Trademark: CMC
- Origin: Suzhou, China
- HS Code: 2812190091
- Supply Ability: 50000kg/Month
- CAS No.: 7803-62-5
- Formula: Sih4
- EINECS: 232-263-4



More Images



Product Description

Product Description

Silane (SiH₄) is a chemical compound that consists of one silicon atom bonded to four hydrogen atoms. Here are some key points about silane:

Structure: Silane has a tetrahedral molecular structure, with the silicon atom at the center and the four hydrogen atoms arranged around it. Its chemical formula is SiH₄.

Properties: Silane is a colorless, flammable gas with a pungent odor. It is less dense than air and can form explosive mixtures when exposed to air.

Silane is highly reactive and can spontaneously ignite in the presence of oxygen.

Production: Silane can be produced through several methods, including the reaction of metallurgical-grade silicon with hydrogen gas, the hydrolysis of silicon tetrachloride (SiCl₄), or the reduction of silicon dioxide (SiO₂) with hydrogen.

Applications: Silane has various applications across different industries:

Semiconductor Industry: Silane is used as a precursor gas in the deposition of thin films of silicon for semiconductor devices. It is a key component in the chemical vapor deposition (CVD) and plasma-enhanced chemical vapor deposition (PECVD) processes.

Solar Energy: Silane is used in the production of silicon-based solar cells. It serves as a precursor gas for depositing silicon layers and dopants onto solar cell substrates.

Surface Modification: Silane is used as a surface treatment agent to enhance adhesion between materials. It is commonly employed in coatings, adhesives, and sealants to improve bonding with substrates such as glass, metals, and plastics.

Chemical Synthesis: Silane derivatives are utilized as reducing agents, intermediates, or catalysts in various chemical reactions. They can be involved in the synthesis of organosilicon compounds, silicones, and other silicon-containing products.

It's important to note that silane is a hazardous substance and requires careful handling due to its flammability and reactivity. Precautions should be taken to ensure safe storage, transportation, and usage of silane.

Basic Info.

| | | | |
|-------------------|------------------------|---------------------|-------------------|
| Model NO. | SiH ₄ | Boiling Point | -112 °C |
| Density | 1.34 Kg/M ³ | Melting Point | -185 °C |
| Cylinder Pressure | 12.5MPa/15MPa/20MPa | Transport Package | 47L/440L/ISO Tank |
| Specification | 47L/440L/ISO Tank | Origin | China |
| HS Code | 2931900090 | Production Capacity | 20, 000tons/Year |

Specification:

CAS No.: 7803-62-5

EINECS No.: 232-263-4

UN No.: UN2203

Purity: 99.9999%

Dot Class: 2.1

Appearance: Colorless

Grade Standard: Electronic Grade

| Specification | 99.9999% |
|--|-------------|
| Carbon Monoxide | ≤ 0.05 ppm |
| Carbon Dioxide | ≤ 0.05 ppm |
| Total chloride | ≤ 0.1 ppm |
| Methane | ≤ 0.05 ppm |
| C2-C4 | ≤ 0.1 ppm |
| Nitrogen | ≤ 0.5 ppm |
| Oxygen | ≤ 0.05 ppm |
| Moisture | ≤ 0.1 ppm |
| Silyl Ether | ≤ 0.1 ppm |
| Methyl Silane | ≤ 0.1 ppm |
| Disilane | ≤ 0.3 ppm |
| Hydrogen | ≤ 20 ppm |
| Aluminum | ≤ 0.02 ppba |
| Antimony | ≤ 0.02 ppba |
| Arsenic | ≤ 0.02 ppba |
| Gallium | ≤ 0.02 ppba |
| Boron | ≤ 0.02 ppba |
| Phosphorus | ≤ 0.02 ppba |
| Iron + Chromium + Nickel + Copper + Zinc | ≤ 1 ppba |

Detailed Photo



Packaging & Shipping

Cylinder Specifications Contents

| Cylinder Capacity | Valve | Weight |
|-------------------|---------|--------|
| 47L | DISS632 | 10 kgs |
| 440L | DISS632 | 120 kg |

Company

Profile



Shanghai Kemike Chemical Co., Ltd is staffed by trained personnel, combine many years experience in Gas industry .We supply cylinder gas, electronic gas, etc ., and the gas holder, panel, valves and fittings and other equipment, parts and engineering services to our customers in China and worldwide; The products are involved in various industrial fields, such as semiconductor chip, solar cell, LED, TFT-LCD, optical fiber, glass, laser, medicine , etc., Our mission is to partner with our

global customers to provide support, solutions and quality products that are innovative, reliable, and safe. Our products mainly include: H₂, O₂, N₂, Ar, CO₂, propane, acetylene, helium, laser mixed gas, SiH₄, SiH₂Cl₂, SiHCl₃, SiCl₄, NH₃, CF₄, NF₃, SF₆, HCL, N₂O, doping mixed gas (TMB, PH₃, B₂H₆) and other electronic gases.

| | | | | | | | | |
|--------------------|--------------------------------|-------------------------------|--|-------------------------------|-------------------------------|-------------------|-------------------|---------------------------------|
| SiCl ₄ | NH ₃ | NH ₃ | CH ₃ F | SiH ₄ | Kr | H ₂ S | WF ₆ | F ₆ +Cl ₂ |
| 4MS | C ₃ F ₈ | C ₃ F ₈ | TEOS | CH ₄ | PH ₃ | SF ₆ | C ₂ | HCl+Ne |
| CF ₄ | C ₄ F ₈ | SiH ₂ |  | | | | | TMB+H ₂ |
| SiF ₄ | C ₃ H ₈ | Cl ₂ | | | | | | He +As |
| BBr ₃ | C ₃ H ₆ | DCE | | | | | | Ge+Se |
| POCl ₃ | N ₂ | SO ₂ | | | | | | D+B |
| BCl ₃ | D ₂ | CO ₂ | | | | | | CO+NO |
| SiHCl ₃ | CH ₂ F ₂ | HF | | | | | | Ar+O ₂ |
| TMAI | DMZn | DEZn | GeH ₄ | C ₂ H ₆ | B ₂ H ₆ | H ₂ Se | GeCl ₄ | Xe+NO |



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